

IN THE CLAIMS:

Please replace claim 1 with the following:

1. (Amended) A method of fabricating a liquid crystal display device, comprising the steps of:

forming a first metal layer on a substrate to form a gate line including a gate electrode, a gate pad, and a first capacitor electrode;

forming an insulating layer, an active layer, and a second metal layer on the substrate;

patterning the second metal layer to form a data line including a data pad, a source electrode, a drain electrode, and a second capacitor electrode;

forming a passivation layer to cover the second metal layer;

forming a photoresist on the passivation layer;

exposing the photoresist using a mask having a light shielding portion, a light transmissive portion, and a semi-transmissive portion;

forming a first photoresist portion, a second photoresist portion, and a third photoresist portion;

patterning the passivation layer, the active layer, and the insulating layer; and

forming a pixel electrode on the passivation layer such that the pixel electrode electrically contacts an upper surface of the second capacitor electrode through a contact hole formed in the insulating layer.